

Charles W Teplin

List of Publications by Year in descending order

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45

papers

960

citations

430874

18

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434195

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45

docs citations

45

times ranked

962

citing authors

#	ARTICLE	IF	CITATIONS
1	Comparison of thin epitaxial film silicon photovoltaics fabricated on monocrystalline and polycrystalline seed layers on glass. <i>Progress in Photovoltaics: Research and Applications</i> , 2015, 23, 909-917.	8.1	9
2	Device Physics of Heteroepitaxial Film c-Si Heterojunction Solar Cells. <i>IEEE Journal of Photovoltaics</i> , 2013, 3, 230-235.	2.5	8
3	600 mV epitaxial crystal silicon solar cells grown on seeded glass. , 2013, , .		4
4	Improved 750 °C epitaxial crystal silicon solar cells through impurity reduction. , 2013, , .		1
5	Device physics of heteroepitaxial film c-Si heterojunction solar cells. , 2013, , .		0
6	Towards Low-cost >15% Efficient Film c-Si Solar Cells: Progress & Challenges. , 2012, , .		3
7	Dislocation-limited open circuit voltage in film crystal silicon solar cells. <i>Applied Physics Letters</i> , 2012, 101, 123510.	3.3	6
8	Device physics of heteroepitaxial film c-Si heterojunction solar cells. , 2012, , .		1
9	Measurement of electric-field induced second harmonic generation in hydrogenated amorphous silicon. <i>Applied Physics Letters</i> , 2012, 101, 161604.	3.3	6
10	Hydrogenation of dislocation-limited heteroepitaxial silicon solar cells. , 2012, , .		1
11	Heteroepitaxial film silicon solar cell grown on Ni-W foils. <i>Energy and Environmental Science</i> , 2012, 5, 6052.	30.8	40
12	Pyramidal light trapping and hydrogen passivation for high-efficiency heteroepitaxial (100) crystal silicon solar cells. <i>Energy and Environmental Science</i> , 2012, 5, 8193.	30.8	21
13	Biaxially-textured photovoltaic film crystal silicon on ion beam assisted deposition CaF ₂ seed layers on glass. <i>Energy and Environmental Science</i> , 2012, 5, 6905.	30.8	30
14	Heteroepitaxial film crystal silicon on Al ₂ O ₃ : new route to inexpensive crystal silicon photovoltaics. <i>Energy and Environmental Science</i> , 2011, 4, 3346.	30.8	33
15	High rate hot-wire chemical vapor deposition of silicon thin films using a stable TaC covered graphite filament. <i>Thin Solid Films</i> , 2011, 519, 4585-4588.	1.8	14
16	Hot-wire chemical vapor deposition of epitaxial film crystal silicon for photovoltaics. <i>Thin Solid Films</i> , 2011, 519, 4545-4550.	1.8	38
17	Epitaxial crystal silicon absorber layers and solar cells grown at 1.8 microns per minute. , 2011, , .		8
18	Junction transport in epitaxial film silicon heterojunction solar cells. , 2011, , .		3

#	ARTICLE	IF	CITATIONS
19	Material quality requirements for efficient epitaxial film silicon solar cells. <i>Applied Physics Letters</i> , 2010, 96, 073502.	3.3	43
20	Mechanisms controlling the phase and dislocation density in epitaxial silicon films grown from silane below 800°C. <i>Applied Physics Letters</i> , 2010, 96, .	3.3	23
21	Physics and chemistry of hot-wire chemical vapor deposition from silane: Measuring and modeling the silicon epitaxy deposition rate. <i>Journal of Applied Physics</i> , 2010, 107, 054906.	2.5	12
22	Photovoltaic device characterization with optical second harmonic generation. , 2010, , .		1
23	Photovoltaic-quality silicon epitaxy by hot-wire CVD at glasscompatible temperatures. , 2009, , .		0
24	Epitaxial film silicon solar cells fabricated by hot wire chemical vapor deposition below 750°C. , 2009, , .		0
25	Phase evolution in nanocrystalline silicon films: Hydrogen dilution and the cone kinetics model. <i>Philosophical Magazine</i> , 2009, 89, 2461-2468.	1.6	1
26	Doping of high-quality epitaxial silicon grown by hot-wire chemical vapor deposition near 700°C. <i>Thin Solid Films</i> , 2009, 517, 3496-3498.	1.8	21
27	The Remarkable Thermal Stability of Amorphous In-Zn-O Transparent Conductors. <i>Advanced Functional Materials</i> , 2008, 18, 3169-3178.	14.9	155
28	Recent advances in hot-wire CVD R&D at NREL: From 18% silicon heterojunction cells to silicon epitaxy at glass-compatible temperatures. <i>Thin Solid Films</i> , 2008, 516, 743-746.	1.8	20
29	Cone Kinetics Model: Insights into the Morphologies of Mixed-phase Silicon Film Growth. <i>Materials Research Society Symposia Proceedings</i> , 2008, 1066, 1.	0.1	0
30	Hot-Wire Chemical Vapor Deposition Epitaxy on Polycrystalline Silicon Seeds on Glass. <i>Materials Research Society Symposia Proceedings</i> , 2007, 989, 16.	0.1	5
31	Comparative Study of Hot-Wire Chemical Vapor Deposition onto (100) Si Near 600°C: Epitaxial and Polycrystalline Silicon Films. <i>Materials Research Society Symposia Proceedings</i> , 2007, 989, 12.	0.1	0
32	A new approach to thin film crystal silicon on glass: Biaxially-textured silicon on foreign template layers. <i>Journal of Non-Crystalline Solids</i> , 2006, 352, 984-988.	3.1	64
33	Significant improvement in silicon chemical vapor deposition epitaxy above the surface dehydrogenation temperature. <i>Journal of Applied Physics</i> , 2006, 100, 093520.	2.5	29
34	Low-temperature silicon homoepitaxy by hot-wire chemical vapor deposition with a Ta filament. <i>Journal of Crystal Growth</i> , 2006, 287, 414-418.	1.5	26
35	Physics of Solid-Phase Epitaxy of Hydrogenated Amorphous Silicon for Thin Film Si Photovoltaics. <i>Materials Research Society Symposia Proceedings</i> , 2006, 910, 5.	0.1	2
36	Breakdown physics of low-temperature silicon epitaxy grown from silane radicals. <i>Physical Review B</i> , 2006, 74, .	3.2	19

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37	Material structure and metastability of hydrogenated nanocrystalline silicon solar cells. <i>Applied Physics Letters</i> , 2006, 88, 263507.	3.3	67
38	Roughness, impurities and strain in low-temperature epitaxial silicon films grown by tantalum filament hot-wire chemical vapor deposition. <i>Materials Research Society Symposia Proceedings</i> , 2006, 910, 1.	0.1	2
39	The electrical, optical and structural properties of $\text{In}_x\text{Zn}_{1-x}\text{O}_y$ ($0 \leq x \leq 1$) thin films by combinatorial techniques. <i>Measurement Science and Technology</i> , 2005, 16, 90-94.	2.6	57
40	Silicon homoepitaxy using tantalum-filament hot-wire chemical vapor deposition. <i>Materials Research Society Symposia Proceedings</i> , 2005, 862, 231.	0.1	5
41	Monitoring and modeling silicon homoepitaxy breakdown with real-time spectroscopic ellipsometry. <i>Journal of Applied Physics</i> , 2005, 97, 103536.	2.5	36
42	Optical surface second harmonic measurements of isotropic thin-film metals: Gold, silver, copper, aluminum, and tantalum. <i>Journal of Applied Physics</i> , 2004, 96, 3626-3634.	2.5	116
43	Combinatorial Growth and Analysis of the Transparent Conducting Oxide $\text{ZnO}/\text{In}(\text{IZO})$. <i>Macromolecular Rapid Communications</i> , 2004, 25, 344-347.	3.9	17
44	Experimental example of isotropic surface second-harmonic generation: dc-sputtered air-exposed aluminum thin films. <i>Physical Review B</i> , 2002, 65,	3.2	12
45	Simultaneous measurement of the surface and bulk magnetization in thin magnetic films. <i>Journal of Applied Physics</i> , 2001, 89, 7168-7170.	2.5	1